



IPW

PATENT
P57036

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

SOK-SAN KIM et al.

Serial No.: 10/811,949

Examiner: *to be assigned*

Filed: 30 March 2004

Art Unit: 2879

For: CHASSIS BASE FOR PLASMA DISPLAY PANEL

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O.Box 1450
Alexandria, VA 22313-1450

Sir:

In accordance with 37 C.F.R. §1.56, and §§1.97 and 1.98 as amended, Applicant cites, describes, and provides copies of the following art references:

FOREIGN PATENT REFERENCE

- Korean Patent Publication No. 10-2003-0016498 A to Bang et al., entitled PLASMA DISPLAY DEVICE, published on 3 March 2003.

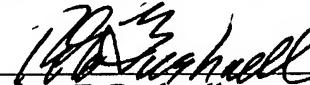
DISCUSSION

Bang et al.'498, which was cited in an Office Action of the basic Korean Patent Application of this U.S. patent application, discusses a plasma display device that achieves improved reliability by reinforcing bending strength of chassis base, and improved radiation and EMI shielding effects.

The citation of the foregoing references is not intended to constitute an assertion that other or more relevant art does not exist. Accordingly, the Examiner is requested to make a wide-ranging and thorough search of the relevant art.

No fee is incurred by this Statement.

Respectfully submitted,



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Folio: P57036
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I.D.: REB/gc

INFORMATION DISCLOSURE STATEMENT PTO-1449 (PAGE 1 OF 1)		SERIAL NUMBER 10/811,949	DOCKET NO. P57036
 APPLICANT SOK-SAN KIM			
FILING DATE 30 March 2004		GROUP 2879	

~~145~~ PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

TRANSLATION

GENERAL INFORMATION							
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	YES	NO
	10-2003-0016498		KOREA			abstract	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)

EXAMINER: _____ DATE CONSIDERED: _____

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP §609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.